

IN THE SPECIFICATION:

Please amend page 5, paragraph 3, as follows:

(1) A thin film containing a photocatalyst semiconductor material is formed over the entire surface of the silicone rubber sheet 2. The photocatalyst semiconductor material is selected from a group consisting of TiO₂, ZnO, SnO₂, SrTiO₃, WO₃, Bi₂O₃ and Fe₂O₃ (for further detail, see Japanese Patent No. 2756474, or corresponding U.S. Pat. No. 6,013,372 A, especially col. 10, line 41 to col. 12, and EP Pat. No. 0816466 A).